Electronic Supporting Information

for

On the impact of metal ions proportion on physical properties of heterometallic metal-organic frameworks

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Table S1. The Na and K content determined by the ICP-OES analysis

Sample	Na (mol%)	K (mol%)
$[CH_3CH_2NH_3][K_{0.04}Na_{0.46}Cr_{0.5}(HCOO)_3]$**(2)**	91.5	8.2
$[CH_3CH_2NH_3][K_{0.22}Na_{0.28}Cr_{0.5}(HCOO)_3]$ **(3)**	56.1	43.4

Table S2. The results of Rietveld refinement for samples with x = 0.04 and 0.22 compared to the literature data for $[CH_3CH_2NH_3][Na_{0.5}Cr_{0.5}(HCOO)_3]$ (x = 0) and $[CH_3CH_2NH_3][K_{0.5}Cr_{0.5}(HCOO)_3]$ (x = 1)

Sample	x	*a* (Å)	*b* (Å)	*c* (Å)	*β* (Å)	V (Å^3)
$[CH_3CH_2NH_3][Na_{0.5}Cr_{0.5}(HCOO)_3]$**(1)**	0	8.1047(1)	9.2639(1)	12.0459(1)	91.1766(10)	904.24(2)
$[CH_3CH_2NH_3][K_{0.04}Na_{0.46}Cr_{0.5}(HCOO)_3]$ **(2)**	0.04	8.1125	9.2897	12.0664	91.20	909.36
$[CH_3CH_2NH_3][K_{0.22}Na_{0.28}Cr_{0.5}(HCOO)_3]$ **(3)**	0.22	8.0985	9.4155	12.1641	90.96	927.53
$[CH_3CH_2NH_3][K_{0.5}Cr_{0.5}(HCOO)_3]$ **(4)**	1	8.0147(2)	9.8547(3)	12.3886(3)	90.052(3)	978.48(5)

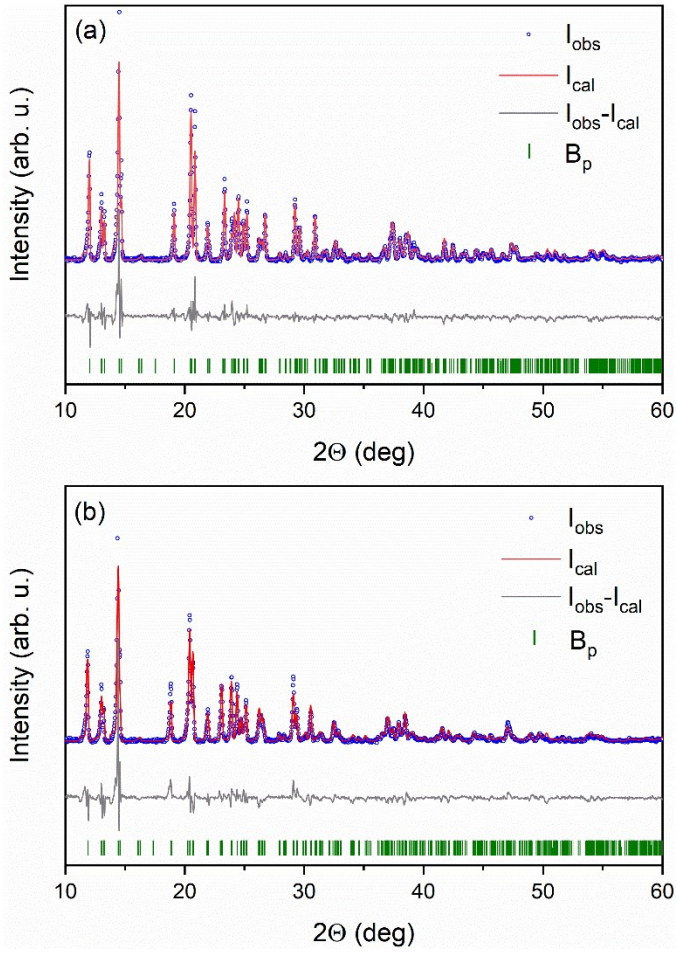

Figure S1. Experimental (I_{obs}), calculated (I_{cal}) anddifference (I_{obs}-I_{cal}) XRD patternstogether with Bragg positions (B_p) for the x = 0.04 **(2)** (a) and x = 0.22**(3)** (b) samples; resulting parameters of fitting: R_p = 3.38, wR_p = 5.09, Gof = 11.99 (for x = 0.4) and R_p = 3.48, wR_p = 5.88, Gof = 14.62 (for x = 0.22)

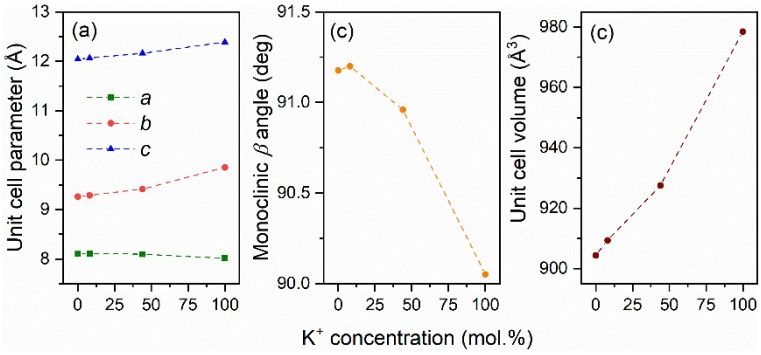

Figure S2. Evolution of unit cell parameters as a function of K^+ concentration

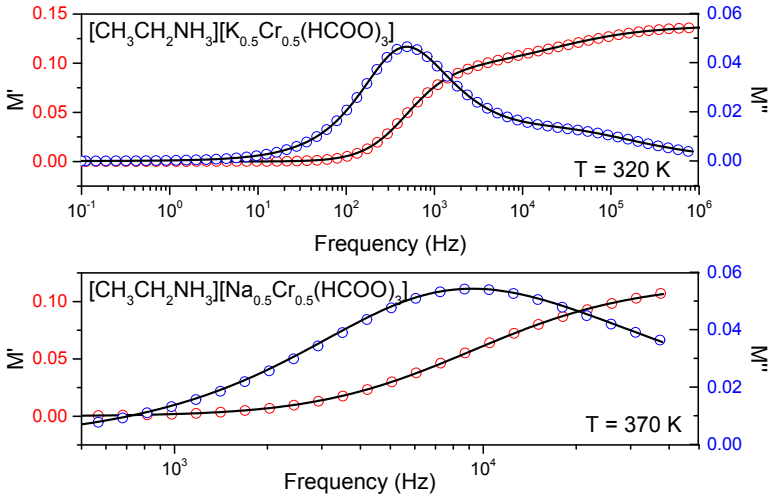

Figure S3. Frequency dependence of the complex dielectric permittivity